

Docket No.: 4425-168

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

LU, YEN-TING

U.S. Patent Application No. 09/919,868

Filed: August 2, 2001

For: METHOD FOR REDUCING LINE EDGE ROUGHNESS OF PHOTORESIST

BOX OFFICIAL DRAFTSMAN

: Confirmation No. 4176

: Group Art Unit: 1756

: Allowed: February 11, 2004

: Examiner: Christopher G. Young

LETTER SUBMITTING FORMAL DRAWINGS

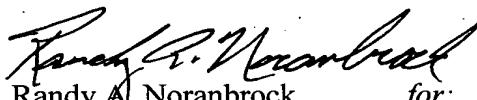
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Submitted herewith are 6 sheets of Replacement Formal Drawings in connection with the above referenced application.

Respectfully submitted,

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